EDWARDS & ANGELL, LLP

COUNSELLORS AT LAW since **1894**

101 FEDERAL STREET BOSTON, MA 02110-1800 (617) 439-4444 FAX (617) 439-4170

Peter F. Corless Direct Dial: (617) 517-5557 E-Mail: pcorless@ealaw.com

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July 3, 2002

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GROUP TOO OFFICIAL United States Patent and Trademark Office

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FAX NO.:

1-703-872-9310

FROM:

Peter F. Corless

TEL. NO.:

(617) 523-3400

FAX NO.:

(617) 523-6440

MESSAGE: Re:

U.S.S.N. 09/605,442, filed June 28, 2000

Attorney Docket No.: 50439-2

In connection with the above-referenced application attached please find:

Amendment Transmittal; and (1)

Second Preliminary Amendment. **(2)**

TOTAL NUMBER OF PAGES: 25_, including cover sheet.

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Docket No. 50439-2

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT:

Barstad et al.

SERIAL NO.:

09/605,442

EXAMINER: W. Nicholas

FILED:

June 28, 2000

GROUP:

1741

FOR:

ELECTROLYTIC COPPER ELECTROPLATING COMPOSITIONS

GROUP TOO THE HONORABLE COMMISSIONER OF PATENTS AND TRADEMARKS WASHINGTON, DC 20231

07/25/2002 ASTRELET 00000001 041105 09605442

SECOND PRELIMINARY AMENDMENT

Please amend the above-identified application as follows.

IN THE CLAIMS

Please cancel claims 21-23 without prejudice.

An article of manufacture comprising: 28. (amended)

a semiconductor wafer substrate having one or more microvias that have an aspect ratio of at least about 4:1 and a diameter of about 200 nm or less,

one or more microvias containing therein an electrolytic copper deposit obtained from an electroplating composition that comprises at least one soluble copper salt, an electrolyte, and one or more brightener compounds having a molecular weight of about 1000 or less and that are present in a concentration of at least about 1.5 mg per liter of the electroplating composition.

An article of manufacture comprising: (amended) 51.

a semiconductor wafer substrate having one or more microvias that have an aspect ratio of at least about 4:1 and a diameter of about 200 nm or less,

one or more microvias containing therein an electrolytic copper deposit obtained from an